

***Interactive comment on “Chamber simulation of photooxidation of dimethyl sulfide and isoprene in the presence of NO<sub>x</sub>” by T. Chen and M. Jang***

**T. Chen and M. Jang**

mjang@ufl.edu

Received and published: 27 September 2012

The comment was uploaded in the form of a supplement:  
<http://www.atmos-chem-phys-discuss.net/12/C7523/2012/acpd-12-C7523-2012-supplement.pdf>

---

Interactive comment on Atmos. Chem. Phys. Discuss., 12, 14669, 2012.